Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	33	johnson-mitchell-\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 13:29
<b>S2</b>	0	patel-vinu-\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 13:30
S3	10	patel-vinu.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 13:45
S4	-	(("1901536") or ("1972754") or ("1988985") or ("2112361") or ("2171806") or ("2723999") or ("2915554") or ("3493424") or ("3787351") or ("4351736") or ("4680212") or ("4781844") or ("4833009") or ("4875901") or ("4937123") or ("4940757") or ("4963409") or ("5001004") or ("5061763") or ("5073442")).PN.	USPAT	OR	OFF	2006/07/28 14:02
<b>S</b> 5	3	S4 and silsesquioxane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 14:54
S6	12	(("5074883") or ("5098774") or ("5212272") or ("5300357") or ("5310828") or ("5460887") or ("5665776") or ("5728669") or ("6187738") or ("6468587") or ("6736857") or ("4883839")).PN.	USPAT	OR	OFF	2006/07/28 14:05
<b>S</b> 7	2	S6 and silsesquioxane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 14:06
S8	2	S4 and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 14:55

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S9	2	S6 and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 14:54
S10	2	"20030194447"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 17:09
S11	224	silsesquioxane and surfactant and peroxide	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/28 17:10
S12	4	silsesquioxane same surfactant same peroxide	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 18:49
S13	11	cekada-joseph-\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 15:46
S14	0	"10815277"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 15:46
S15	1	10/815277.app.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:04
S16	272	"acrylic acid" same acrylate same homolog	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:05
S17	20	"acrylic acid" near6 acrylate near6 homolog	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:16
S18	3	emulsion near2 polymerization and "sequestering agent" and silsesquioxane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:18

S19	501	emulsion near2 polymerization and "sequestering agent"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:18
S20	298	emulsion near2 polymerization and "sequestering agent" and peroxide	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:18
S22	4	emulsion near2 polymerization and "sequestering agent" and peroxide and silane and "510"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/29 18:19
S23	55	emulsion near2 polymerization and "sequestering agent" and peroxide and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 18:37
S24	13	silsesquioxane and surfactant and peroxide and latex and (chelat\$5 or sequest\$7)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 20:06
S25	0	"33555406"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 20:06
S26	0	"33555406".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 20:06
S27	4	"3355406".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 20:06
S28	6	(sequest\$7 or chelat\$7) same ((emulsion or solution) near2 polymerization) same silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:04
S29	6208	peroxide same (sequest\$7 or chelat\$7)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 11:26

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S30	22	peroxide same (sequest\$7 or chelat\$7) same silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:07
S31	0	peroxide same (stpp or edta) same silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:08
S32	1712	peroxide and (stpp or edta) and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:08
S33	59	peroxide and (stpp or edta) and silane and silsesquioxane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:08
S34	6	peroxide and (stpp or edta) and silane and silsesquioxane and "510"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:14
S35	889	peroxide and (stpp or edta) and silane and polymerization	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/30 21:15
S36	56	peroxide and (stpp or edta) and silane and polymerization and "510"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 09:38
S37	400	peroxide and carpet and "510"/\$. ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 10:52
S38	5	peroxide and carpet and "510"/\$. ccls. and silsesquioxane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 09:47
S39	1	peroxide and carpet and "510"/\$. ccls. and poly\$silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 10:36

S40	0	"67365857" and peroxide	US-PGPUB;	OR	ON	2006/07/31 10:37
3.0	v	07303037 una peroxide	USPAT; USOCR; EPO; JPO; DERWENT			2000/07/02 20:07
S42	0	"67365857" and perox\$5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 10:37
S43	374	peroxide and carpet and "510"/\$. ccls. and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 10:52
S44	57	peroxide same carpet and "510"/\$. ccls. and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 10:53
S45	66	peroxide same (sequest\$7 or chelat\$7) and carpet and "510"/\$. ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 11:37
S46	0	"sodium xylene sulfonate" and "nonylphenol glycol ether" and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 11:38
S47	6	"sodium xylene sulfonate" and "nonylphenol polyethylene glycol ether" and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 12:56
S48	350	silsesquioxane and ("methacyrlic acid" or polymethacyrlic acid) and ("hydrogen peroxide" or t-butyl peroxide or perborate or percarbonate) and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 13:34
S49	110	silsesquioxane and ("methacyrlic acid" or polymethacyrlic acid) and ("hydrogen peroxide" or "t-butyl peroxide" or perborate or percarbonate) and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 13:35

S50	16	silsesquioxane and ("methacyrlic acid" or polymethacyrlic acid) and ("hydrogen peroxide" or "t-butyl peroxide" or perborate or percarbonate) and surfactant and "510"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 13:35
S51	12	(("5074883") or ("5098774") or ("5212272") or ("5300357") or ("5310828") or ("5460887") or ("5665776") or ("5728669") or ("6187738") or ("6468587") or ("6736857") or ("4883839")).PN.	USPAT	OR	OFF	2006/07/31 18:31
S52	114	chang-john-\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 18:32
S53	33	chang-john-c.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/07/31 18:32

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          6337 SILSESQUIOXANE
          9883 SILSESQUIOXANES
Ll
         10731 SILSESQUIOXANE
                 (SILSESQUIOXANE OR SILSESQUIOXANES)
=> s hydrogen peroxide
        934292 HYDROGEN
          5787 HYDROGENS
        937530 HYDROGEN
                 (HYDROGEN OR HYDROGENS)
        204205 PEROXIDE
         46130 PEROXIDES
        222278 PEROXIDE
                 (PEROXIDE OR PEROXIDES)
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        109889 HYDROGEN PEROXIDE
                 (HYDROGEN (W) PEROXIDE)
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        163036 SURFACTANTS
        231031 SURFACTANT
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     Mesoporous silica polymers with good thermal and mechanical stability,
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     their manufacture, and their proton-conductive materials
     Mal, Nawal Kishor; Hikuma, Koichiro; Noda, Kazuhiro
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     Sony Corp., Japan
     Jpn. Kokai Tokkyo Koho, 13 pp.
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